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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|---------------------------|-----------------|-------------------------|---------------------|------------------|
| 10/814,640 | 04/01/2004 | Sukesh Sandhu | M4065.0224/P224-A | 7539 |
| 24998 | 7590 09/16/2004 | | EXAM | INER |
| DICKSTEIN 2101 L STREI | SHAPIRO MORIN & | EVERHART, CARIDAD | | |
| WASHINGTON, DC 20037-1526 | | | ART UNIT | PAPER NUMBER |
| | · | | 2825 | |
| | | DATE MAILED: 09/16/2004 | | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | Application No. | Applicant(s) | | | | |
|--|---|-----------------------------|--|--|--|--|
| | 10/814,640 | SANDHU ET AL. | | | | |
| Office Action Summary | Examiner | Art Unit | | | | |
| | Caridad M. Everhart | 2825 | | | | |
| The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply | | | | | | |
| A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). | | | | | | |
| Status | | • | | | | |
| 1) Responsive to communication(s) filed on | | | | | | |
| 2a) This action is FINAL . 2b) ⊠ This | action is non-final. | | | | | |
| ,== | Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. | | | | | |
| Disposition of Claims | | | | | | |
| 4) Claim(s) 6-10 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 6-10 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. | | | | | | |
| Application Papers | | | | | | |
| 9)☐ The specification is objected to by the Examiner. | | | | | | |
| 10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner. | | | | | | |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). | | | | | | |
| Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. | | | | | | |
| Priority under 35 U.S.C. § 119 | | | | | | |
| 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: Certified copies of the priority documents have been received. Certified copies of the priority documents have been received in Application No Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. | | | | | | |
| Attachment(s) | | | | | | |
| 1) Notice of References Cited (PTO-892) | 4) Interview Summary | | | | | |
| 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 4-1-2004. | Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other: | atent Application (PTO-152) | | | | |

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Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 6, and 8-10 are rejected under 35 U.S.C. 102(e) as being anticipated by Lee, et al. (US 5,923,056).

Lee et al disclose the steps of forming a gate dielectric(col. 4,lines 37-39), forming source and drain regions (col. 4, lines 38-42), forming a floating gate(col. 4, lines 45-47), and forming a silicon –doped aluminum oxide layer by CVD on the floating gate(col. 4, lines 52-55 and col. 5, lines 50-53 and col. 3, lines 30-33), col. 3, lines 30-33 indicating that the IPD layer indicated in col. 4, lines 52-55 can be aluminum oxide. The gate dielectric is oxide (col. 4, lines 39-41). The device is a flash memory device(col. 2, lines 54-56). The control gate may have a silicide formed on polysilicon(col. 5, lines 3-5).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lee, et al as applied to claim 6 above and further in view of Ohzone, et al. (US 5,250,455).

Lee et al is silent with respect to the recited energy of implantation and the concentration, as Lee et al is silent with respect to implantation and rather dopes the aluminum oxide in situ in the CVD deposition.

Ohzone et al is relied upon for its teaching of the implantation of silicon in aluminum oxide at the concentration which includes 10 to the power of 15 13 and 14/cm2(col. 3, lines 35-36 and 55-56), which is within the recited range. With respect to

the energy, Ohzone et al discloses that the energy is varied according to the desired results such as the impurity density depth desired(col. 3,lines 60-67 and Fig. 2A and Fig. 2B).

It would have been obvious to one of ordinary skill in the art to have modified the teachings of Lee et al such as to have been able to choose the concentration and the energy of the implantation recited in the claim because Ohzone et al teaches that the recited concentrations were known for the aluminum oxide in order to result in desired characteristics for the device(Ohzone, et al col. 3, lines 43-49), and with respect to the energy because Ohzone et al teaches that the energy is a variable of the art which one of ordinary skill in the art would have been able to adjust according to the desired characteristics as shown by Ohzone et al.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Caridad M. Everhart whose telephone number is 571-272-1892. The examiner can normally be reached on Monday through Fridays 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

CARIDAD EVERHART PRIMARY EXAMINED

C. Everhart 9-10-2004